

# NiO

## NICKEL Oxide SPUTTERING TARGET

Nickel(II) oxide is the chemical compound with the formula NiO. These targets are designed to work with both older sputtering devices as well as with the latest process equipment for large area coating in fuel cells, solar energy, and flip-chip applications. We produce custom sizes, alloys and research sized targets. We specialize in producing custom compositions for new proprietary technologies and commercial and research purposes.

### Quick Facts

Product	:	Nickel Oxide Sputtering Target
Stock No	:	NS6130-10-1320
CAS	:	1313-99-1
Backing Plate	:	(As per Customer requirement)

### Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1320	99.99%	50mm	2mm

### Technical Specification

Molecular Formula	Molecular Weight	Melting Point
NiO	74.69g/mol	1955°C



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High Purity  
SPUTTERING  
TARGET

TARGET



20ZICE4589C



19ZAZGO1274G



20ZICE4588M

ISO 9001:2015  
CERTIFIED COMPANY